



78TH DEVICE RESEARCH CONFERENCE



Thermal Engineering of Volatile Switching in PrMnO₃ RRAM: Non-Linearity in DC IV Characteristics and Transient Switching Speed

J. SAKHUJA, S. LASHKARE, V. SARASWAT AND U. GANGULY
DEPARTMENT OF ELECTRICAL ENGINEERING, IIT BOMBAY,
INDIA

Outline

1 Motivation

2 Introduction to RRAM

3 Thermal Engineering In PMO RRAM

4 Results and Discussion

5 Conclusion

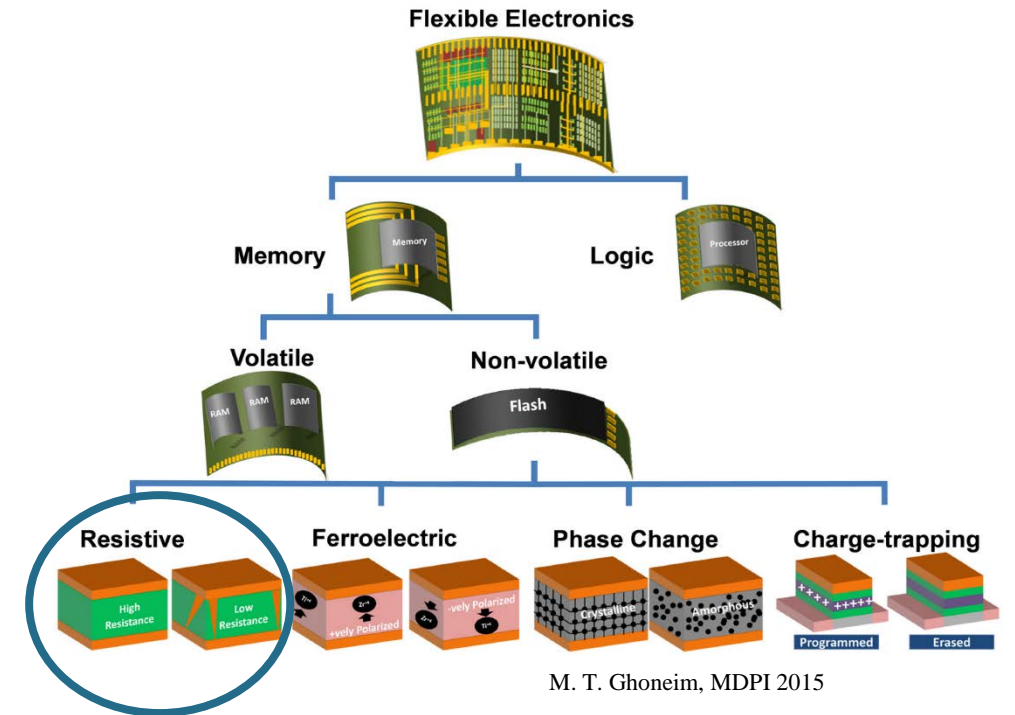
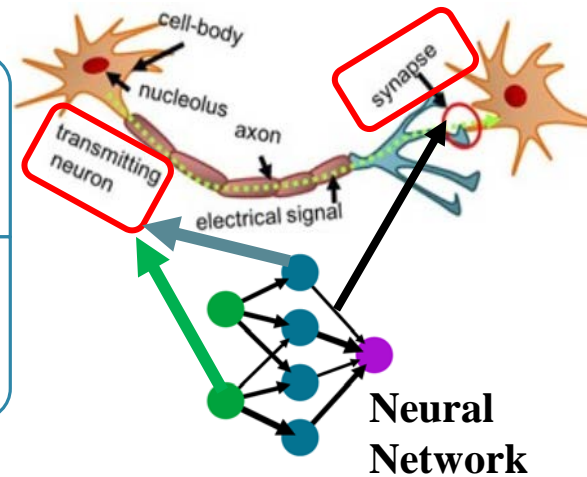
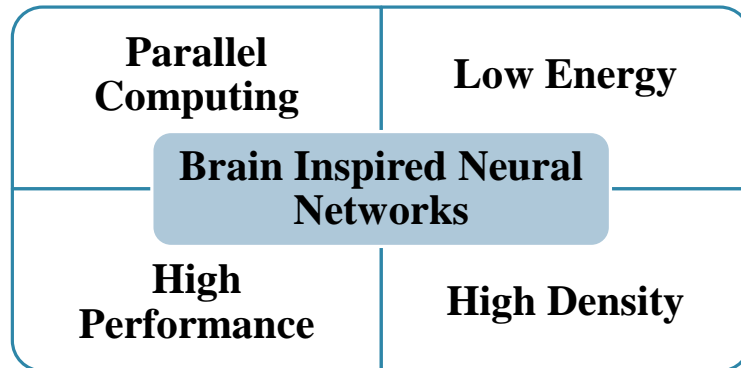
Motivation

Data Driven Applications



- Computing (Volatile Memory)
- Data Storage (Non-Volatile Memory/ Volatile Memory)

Emerging Technologies

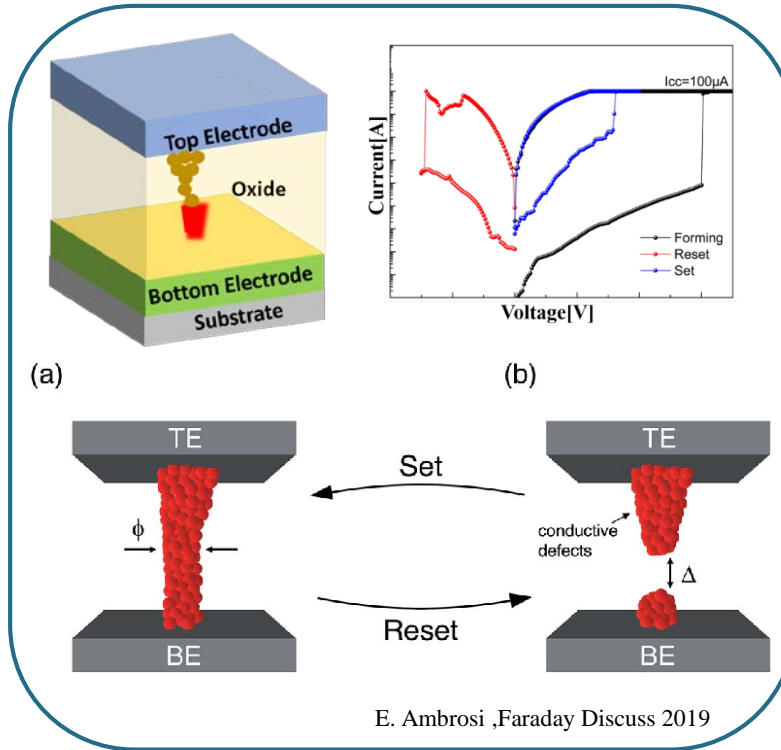


Resistive Random Access Memory (RRAM)

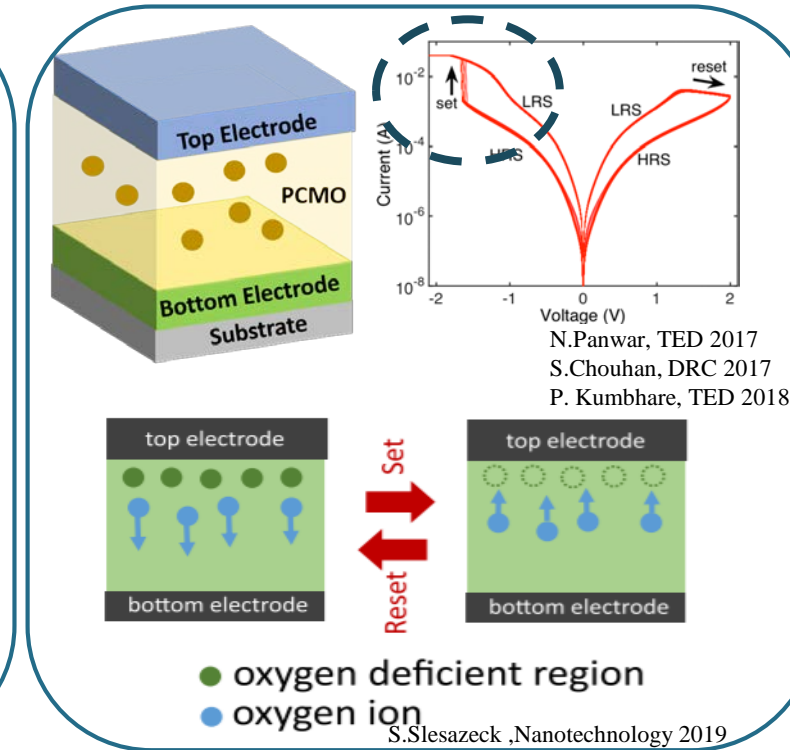
Key Features

- Simple Structure
- High Density
- Low Voltage
- Fast Switching

Filamentary RRAM



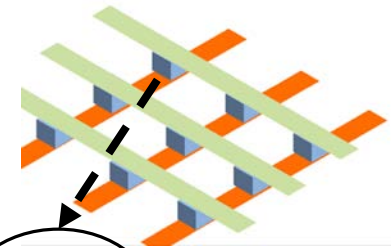
Non-Filamentary RRAM



Physics

- Ionic Transport
- Joule Heating

RRAM Crossbar Array



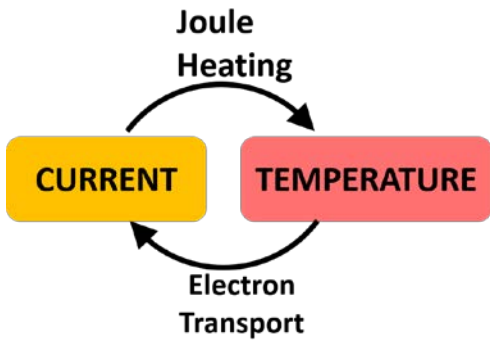
Area
Power
Speed

Selector-less RRAM with enhanced *Non-Linearity* is attractive

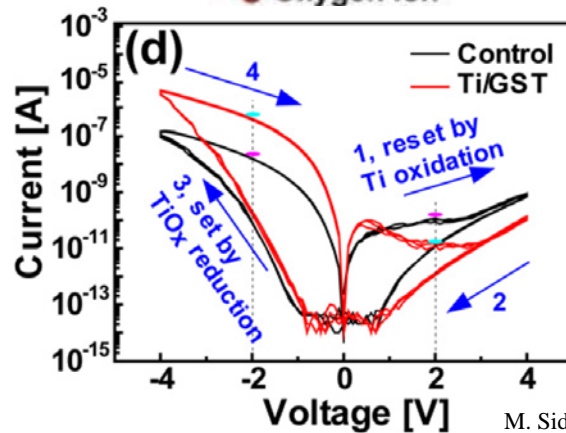
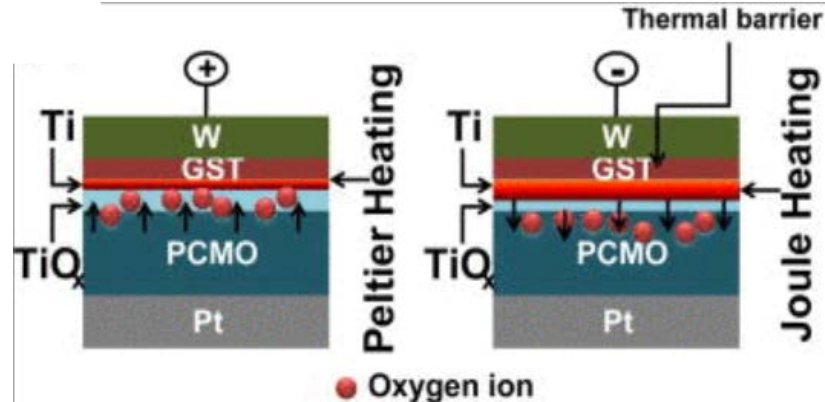


Enhancing Non-Linearity in RRAM

Positive Thermal Feedback

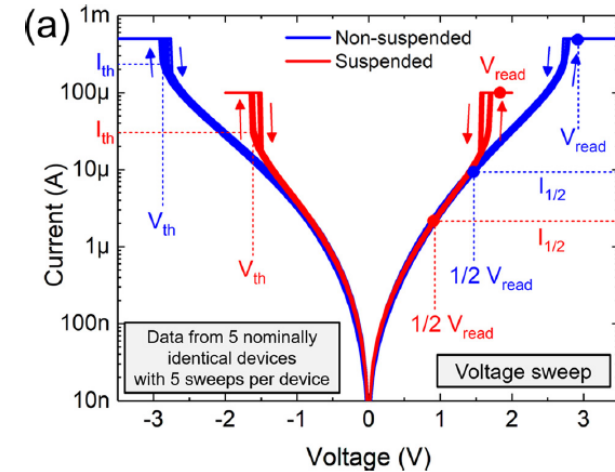
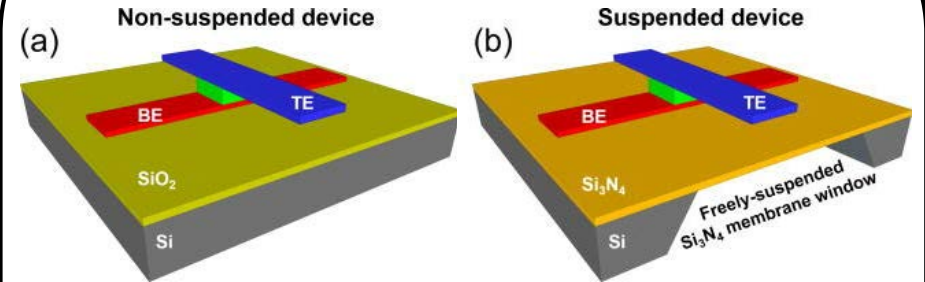


Incorporated Thermally Insulated Layer



M. Siddik, APL, 2011

Substrate Modification



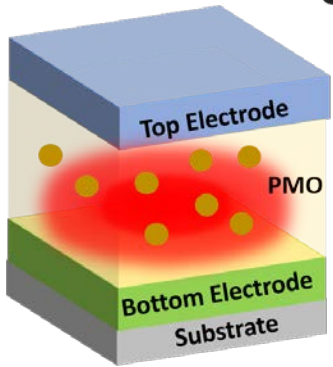
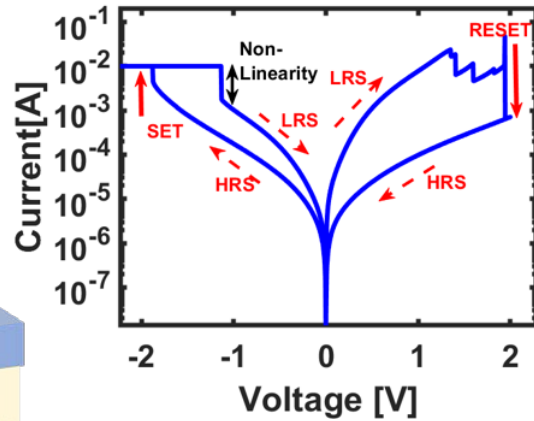
Z. Wang, APL 2018



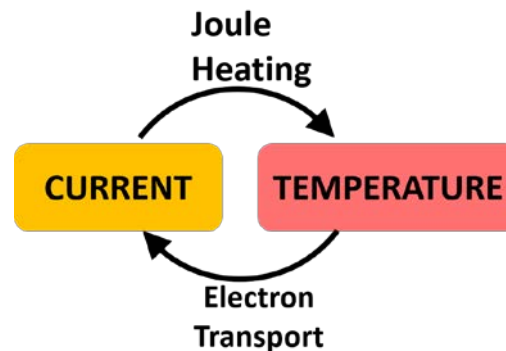
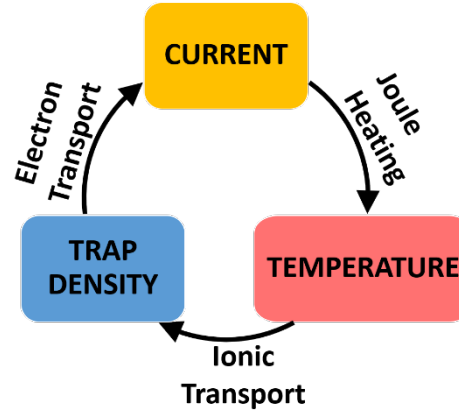
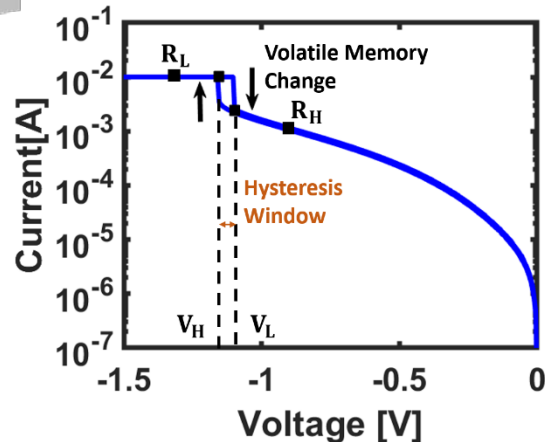
Thermal Engineering is an effective medium to enhance Switching Characteristics

PrMnO₃ Based RRAM

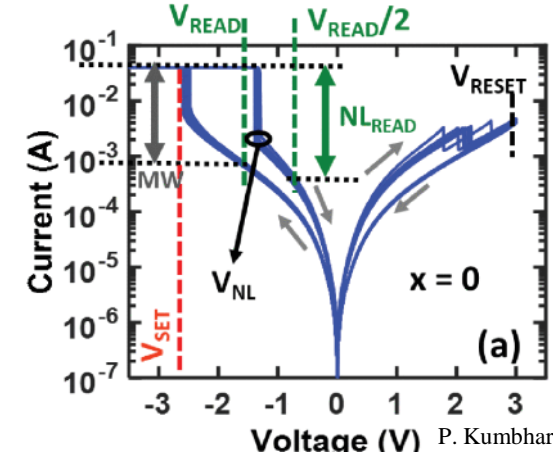
Non-Volatile Switching



Volatile Switching

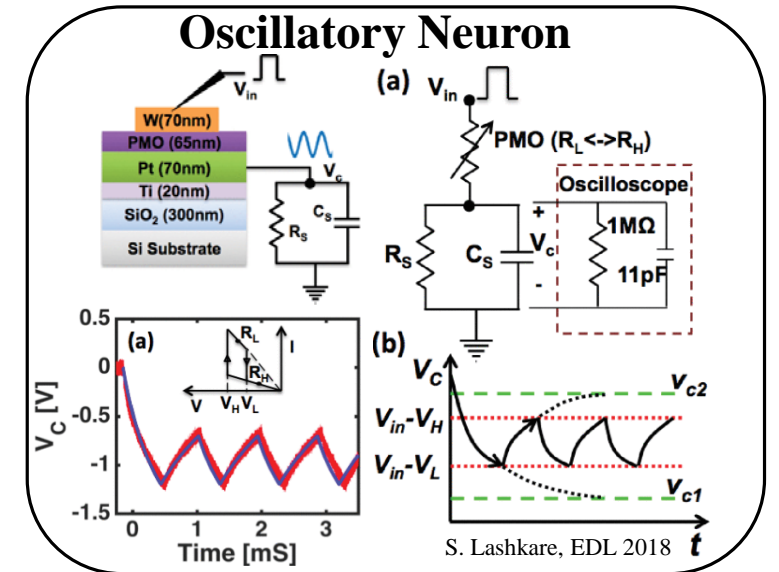


Selector-Less Memory



P. Kumbhare, TED 2018

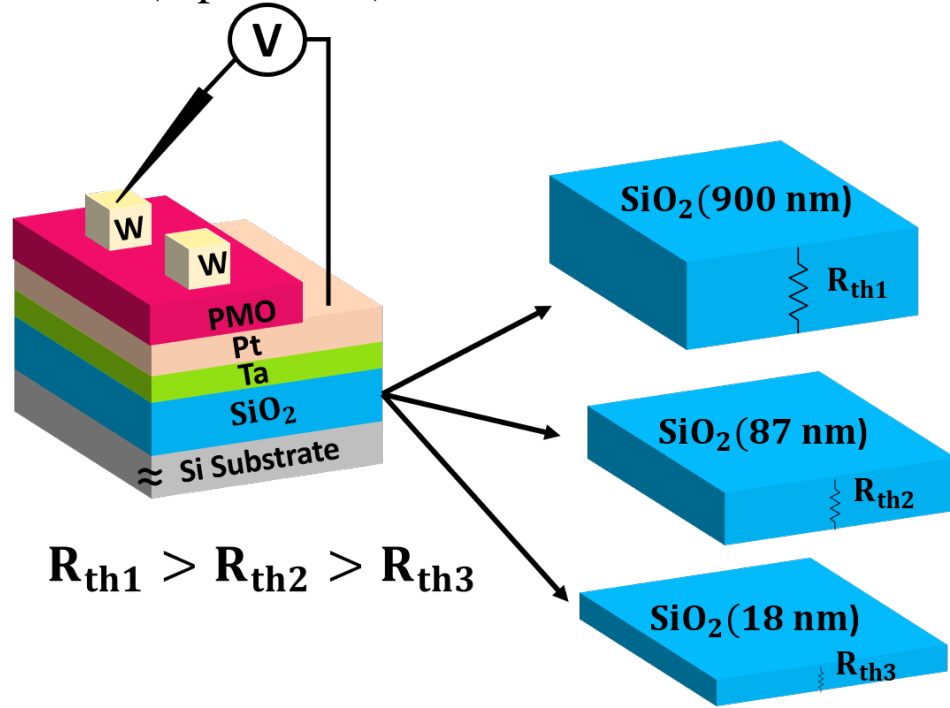
Oscillatory Neuron



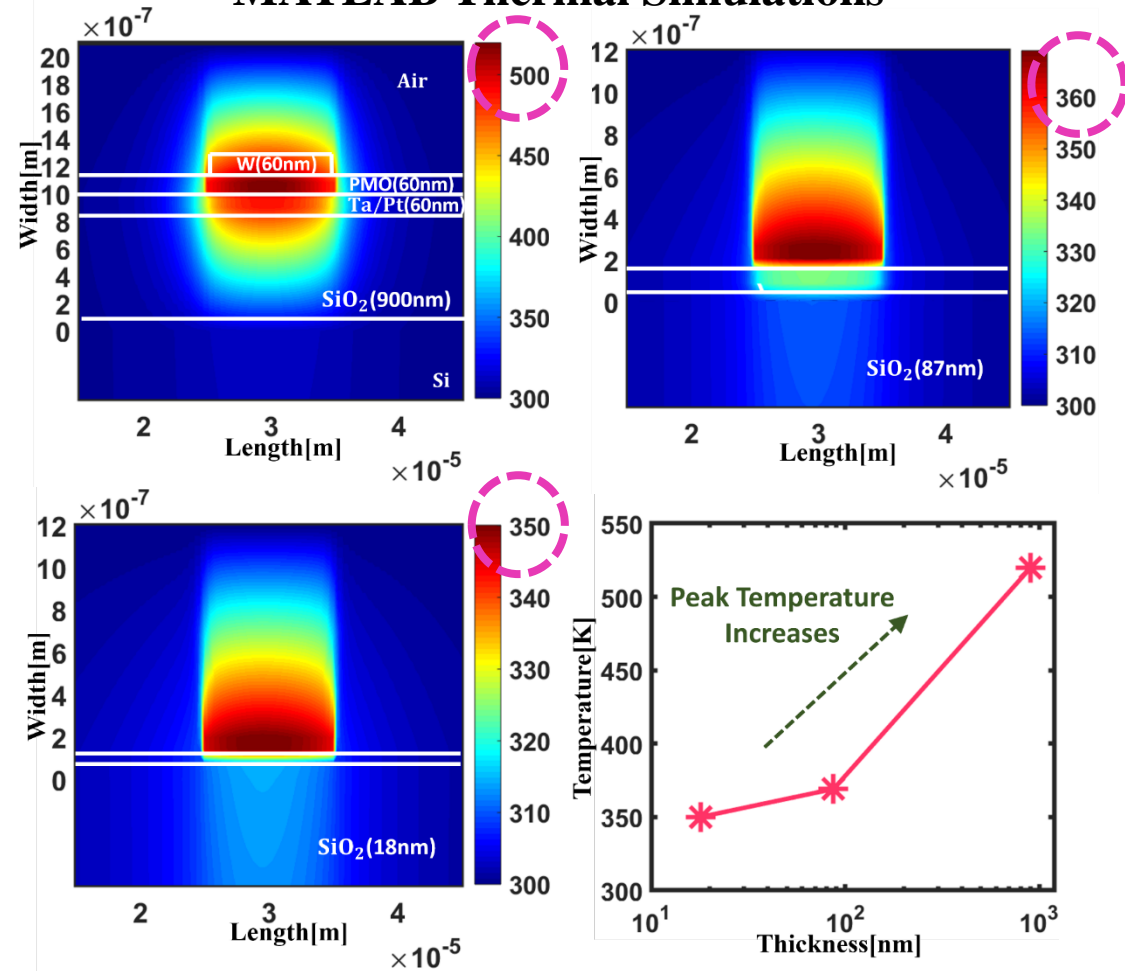
S. Lashkare, EDL 2018

Thermal Engineering of Volatile Hysteresis

10 μm x 10 μm
W area(top contact)

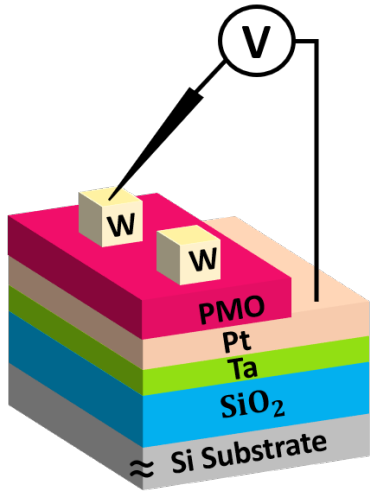


MATLAB Thermal Simulations

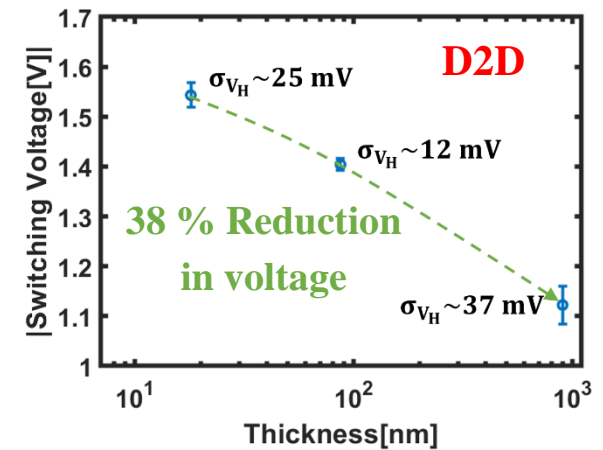
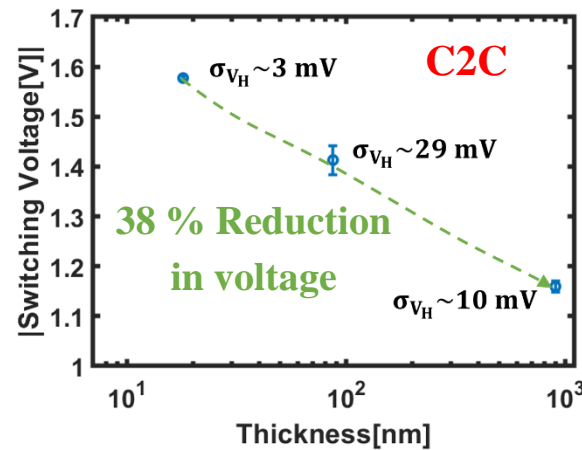
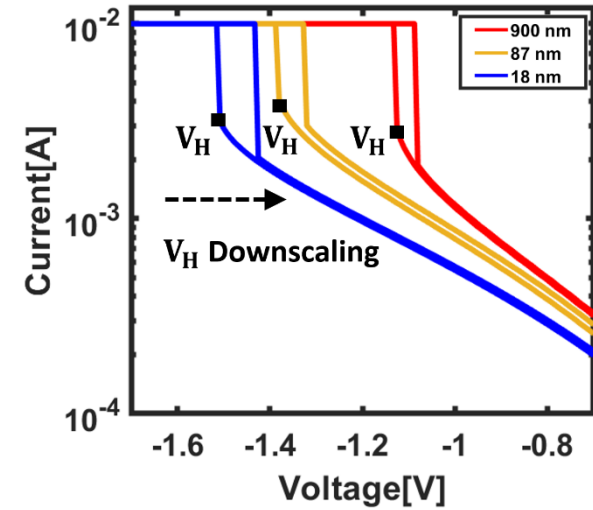
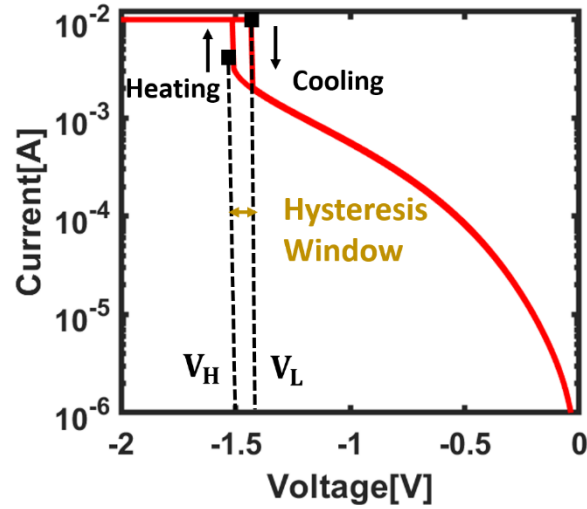


Low Thermal conductivity makes SiO_2 Good Thermal Insulator

Threshold Voltage Scaling (DC-IV Measurements)



Input Voltage
Double Sweep:
-2 V @ 10 mA

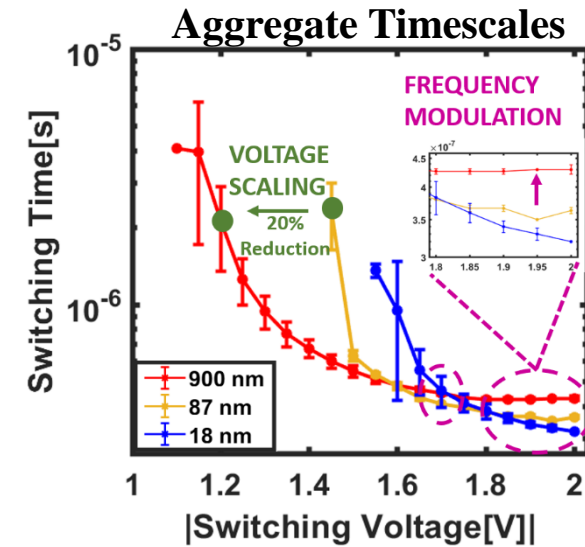
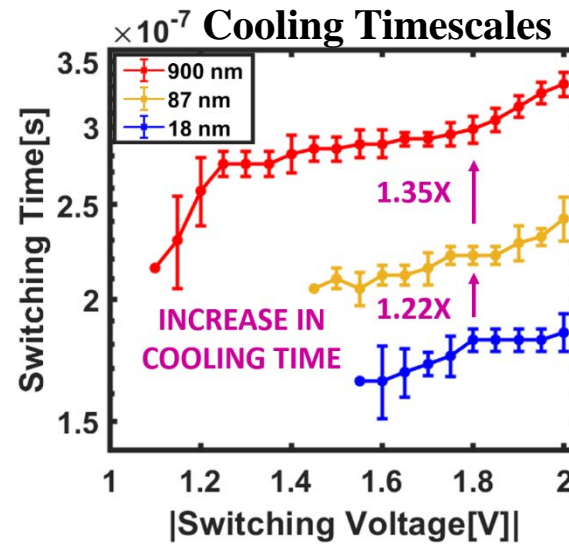
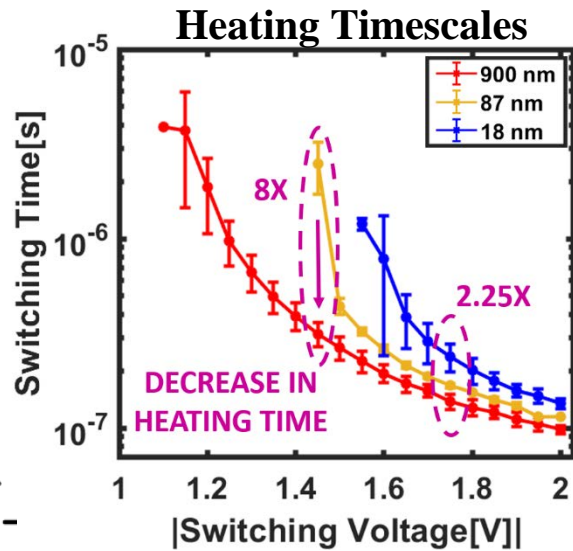
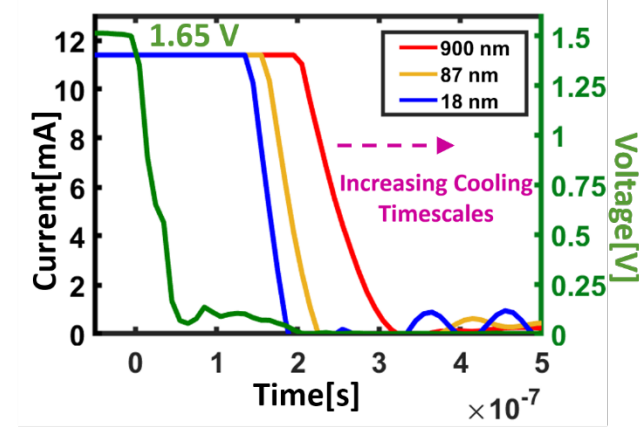
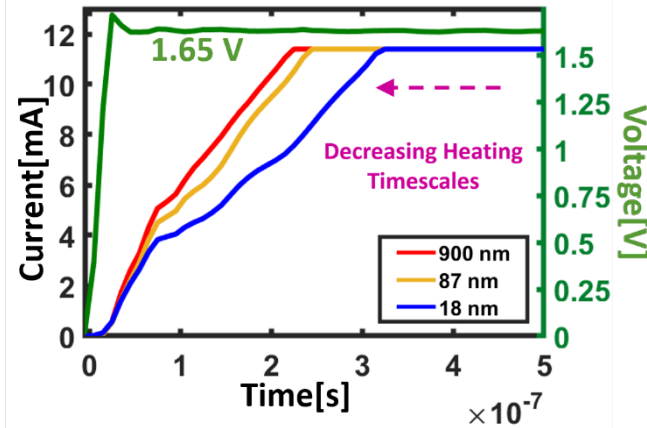


Threshold Voltage Scaling by changing device's thermal resistance



Speed Scaling (Transient Measurements)

Input voltage pulse for voltage range [-1 V to -2 V] @ threshold current of 10mA



Aggregate Timescales gives *voltage benefit* at Lower Voltages and *speed improvement* at Higher Voltages

Conclusion

1. Voltage downscaling by **38 %** in DC and by **20 %** in transient analysis is significant for power efficiency.
2. An **8X** improvement in heating transients is significant for selector-less applications and oscillations.
3. The **aggregate** of Heating and Cooling timescales is important for accurate analysis.
4. An **electro-thermal speed engineering** study is critical for RRAM devices to model elements of neural networks that use NL characteristics

THANK YOU 😊 😊

Questions?